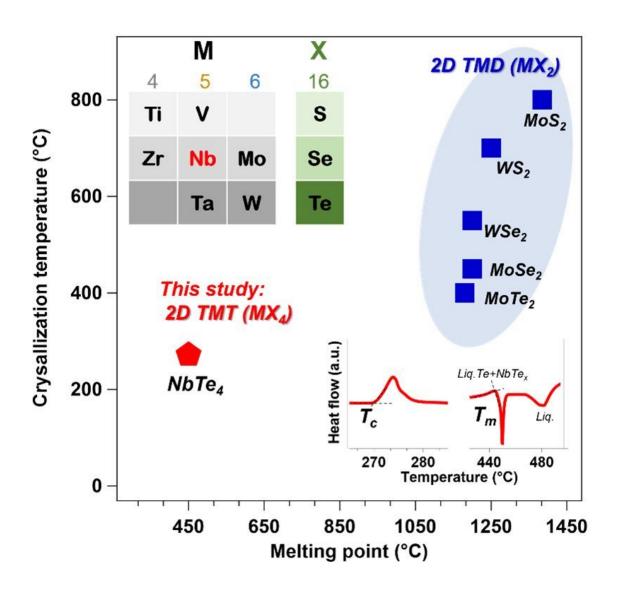


New material shows promise for nextgeneration memory technology

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A comparison of T_c (crystallization temperature) and Tm (melting point) values of various 2D TM chalcogenides; The T_c and Tm values of NbTe₄ were defined by the onset temperature of crystallization and melting peaks in this study.



Credit: Yi Shuang et al.

Phase change memory is a type of nonvolatile memory that harnesses a phase change material's (PCM) ability to shift from an amorphous state, i.e., where atoms are disorganized, to a crystalline state, i.e., where atoms are tightly packed close together. This change produces a reversible electrical property which can be engineered to store and retrieve data.

While this field is in its infancy, <u>phase change memory</u> could potentially revolutionize <u>data storage</u> because of its high storage density, and faster read and write capabilities. But still, the complex switching mechanism and intricate fabrication methods associated with these materials have posed challenges for mass production.

In recent years, two-dimensional (2D) Van Der Waals (vdW) <u>transition</u> <u>metal</u> di-chalcogenides have emerged as a promising PCM for usage in phase change memory.

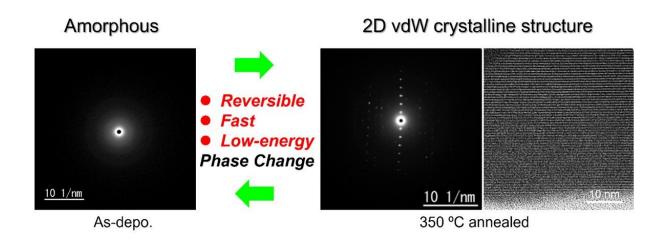
Now, a group of researchers from Tohoku University has highlighted the potential use of sputtering to fabricate large-area 2D vdW tetrachalcogenides. Using this technique, they fabricated and identified an exceptionally promising material—niobium telluride (NbTe₄)—that exhibits an ultra-low melting point of approximately 447 °C (onset temperature), setting it apart from other TMDs. Details of the group's discovery were published in the journal *Advanced Materials*.

"Sputtering is a widely used technique that involves depositing thin films of a material onto a substrate, enabling precise control over film thickness and composition," explains Yi Shuang, assistant professor at Tohoku University's Advanced Institute for Materials Research and co-



author of the paper. "Our deposited NbTe₄ films were initially amorphous, but could be crystallized to a 2D layered crystalline phase by annealing at temperatures above 272 °C."

Unlike conventional amorphous-crystalline PCMs, such as $Ge_2Sb_2Te_5$ (GST), NbTe₄ demonstrates both a low melting point and a high crystallization temperature. This unique combination offers reduced reset energies and improved <u>thermal stability</u> at the amorphous phase.



A selected area electron diffraction and crossectional TEM image of asdeposited and 350 °C annealed NbTe₄ thin films. Credit: Yi Shuang et al.

After fabricating the NbTe₄, the researchers then evaluated its switching performance. It exhibited a significant reduction in operation energy compared to conventional phase-change memory compounds.

The estimated 10-year data retention temperature was found to be as high as 135 °C—better than the 85 °C of GST—suggesting an excellent thermal stability and the possibility of NbTe₄ to be used in high-



temperature environments such as in the automotive industry. Additionally, NbTe₄ demonstrated a fast-switching speed of approximately 30 nanoseconds, further highlighting its potential as a next-generation phase change memory.

"We have opened up new possibilities for developing high-performance phase change memories," adds Shuang. "With NbTe₄'s low melting point, high crystallization temperature, and excellent switching performances, it is positioned as the ideal material to address some of the current challenges face by current PCMs."

More information: Yi Shuang et al, NbTe4 Phase-Change Material: Breaking The Phase-Change Temperature Balance in 2d Van Der Waals Transition-Metal Binary Chalcogenide, *Advanced Materials* (2023). <u>DOI:</u> <u>10.1002/adma.202303646</u>

Provided by Tohoku University

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